

Nanolito

2012

2 µm

5TH SPANISH WORKSHOP ON NANOLITHOGRAPHY

13TH TO 15TH NOVEMBER 2012, SAN SEBASTIAN

The 5th Spanish Workshop on Nanolithography (NANOLITO 2012) is a meeting mainly focused on the research on nanolithography methods performed in Spanish-based centers or institutions, but it kindly welcomes also international contributions. This meeting means to establish an adequate scenario for interregional technology transfer and future collaboration research projects as it was done before in previous workshops in Zaragoza (2007), Barcelona (2008), Madrid (2009) and Oviedo (2010).

There will be both oral (15 min) and poster contributions.

Registration fee: 50€ (includes lunch and conference dinner)

More information at: www.nanogune.eu/en/nanolito2012

Extended deadline for abstract submission: 5th October

Abstract submission: nanolito2012@nanogune.eu

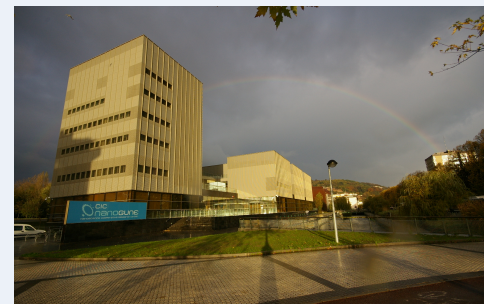
Invited Speakers (confirmed)

- A. Kristensen (Technical University of Denmark)
- C.W. Hagen (Delft University of Technology)
- J. Gierak (LPN-CNRS)
- K. Bouzehouane (CNRS/Thales)
- L. Pain (CEA-LETI)
- M. Morris (University College Cork)

Topics

- Electron and ion-beam lithography
- Electron and ion-beam induced deposition
- Nanoimprint-soft lithography
- Atomic manipulation
- Self-assembly
- Local probe lithography
- Deep-UV lithography

Venue



CIC nanoGUNE Consolider

Nanolito Scientific Committee

José María De Teresa (ICMA, Zaragoza)
Francesc Pérez-Murano (CNM, Barcelona)
Albert Romano (UB, Barcelona)
Ricardo García (IMM, CSIC, Madrid)
Santos Merino (Tekniker, Eibar)
José Ignacio Martín (UNIOVI, Oviedo)

Ricardo Ibarra (INA, Zaragoza)
Luis E. Hueso (CIC nanoGUNE, Donostia)
José Luis Vicent (UCM, Madrid)
Clivia Sotomayor (ICN, Barcelona)
José Luis Prieto (UPM-ISOM, Madrid)
Carles Cané (CNM, Barcelona)

Local Organizing Committee

Luis E. Hueso
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